Short Communication

# On the evaluation of the Marcus-Hush-Chidsey integral 

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## A R T I C L E IN F O

## Article history:

Received 30 January 2012
Received in revised form 26 February 2012
Accepted 27 February 2012
Available online 6 March 2012

## Keywords:

Electron transfer rate
Marcus-Hush-Chidsey integral


#### Abstract

The electrochemical rate constant obtained from the Marcus-Hush theory of heterogeneous electron transfer is given as a relatively complex integral. Recently, two apparently different expressions of this rate constant in the form of a series of analytical functions appeared in the literature. We demonstrate here the equivalence of these expressions and discuss their different approximations, resulting from the two distinct analytical derivations, which have implications in the practical calculation of electron transfer rate constants at electrode surfaces.


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The Marcus-Hush theoretical model of heterogeneous electron transfer [1-3], usefully implemented in the context of electrode reactions [4,5], has been increasingly employed in recent years [6] as an alternative to Butler-Volmer equations. Considering a metal electrode in contact with a redox molecule, and assuming that the electronic coupling between metal and molecule and the density of states in the metal are independent of the energy, one arrives at an expression of the interfacial electron transfer rate constant as an integral of the Fermi-Dirac distribution of the electrons and the Marcus free energy factor, where a potential-dependent activation energy appears. For a single electron transition it can be written as
$R_{\mathrm{ox} / \mathrm{red}}=\frac{\gamma}{2 \sqrt{\pi \lambda k_{B} T}} \int_{-\infty}^{\infty} d x \frac{1}{\exp \left(\frac{x}{k_{B} T}\right)+1} \exp \left[-\frac{(x-\lambda \pm e \Delta E)^{2}}{4 \lambda k_{B} T}\right]$.
In Eq. (1), $\gamma$ is the coupling strength to the electrode, which depends on the electronic coupling and the density of electronic states in the metal. $e, k_{B}$, and $T$ are the electron charge, Boltzmann constant, and temperature, respectively. $\lambda$ is the reorganization energy and $\Delta E$ is the overpotential, The $\pm$ signs refer to the oxidative and reductive transition rate constants. Evaluation of the integral (1) is facilitated by expressing it as a series. This has been first elegantly done in Ref. [7], exploiting the expansion
$\operatorname{sech}(x)=2 \sum_{j=0}^{\infty}(-1)^{j} \exp [-(2 j+1) x]$,

[^0]which leads to the expression
$R_{0 \mathrm{ox} / \text { red }}(\Delta E)=\frac{\gamma}{2} \exp \left[-\frac{( \pm e \Delta E-\lambda)^{2}}{4 \lambda k_{B} T}\right] S(\lambda, \Delta E)$,
where
$S=\sum_{j=0}^{\infty}(-1)^{j} w_{j}$,
with
$w_{j}=\exp \left(\vartheta_{+}^{2}\right) \operatorname{erfc}\left(\vartheta_{+}\right)+\exp \left(\vartheta_{-}^{2}\right) \operatorname{erfc}\left(\vartheta_{-}\right), \quad \vartheta_{ \pm}$
\[

$$
\begin{equation*}
=\frac{(2 j+1) \lambda \pm e \Delta E}{2 \sqrt{\lambda k_{B} T}} . \tag{4b}
\end{equation*}
$$

\]

Moreover, useful approximations to $S$ in different ranges of the overpotential are provided [7].

In Ref. [7], it is noticed that the expansion (2) "fails at $x=0$, but this causes no problems in practice." An alternative procedure, recently offered by us [8], does not use this expansion. Considering that the transition rate constants are most sensitive to the overpotential at $e|\Delta E|=\lambda$ and that, at such $\Delta E$, the integrand in Eq. (1) has a maximum for $x=0$, an optimal series solution of the integral can be obtained by an expansion of the Fermi function describing the electron distribution on the metal levels
$f(\varepsilon)=\frac{1}{\exp \left(\frac{\varepsilon-\mu}{k_{B} T}\right)+1}$,
(where $\varepsilon$ is the metal level energy and $\mu$ is the overpotentialdependent Fermi level of the electrode) that is rapidly convergent and particularly effective at and near $x=0$. Thus we used [8]

$$
\begin{align*}
\frac{1}{\exp (x)+1} & =\frac{\exp (-x)}{1+\exp (-x)}=\frac{1}{2} \frac{\exp (-x)}{1-[1-\exp (-x)] / 2} \\
& =\frac{1}{2} \exp (-x) \sum_{n=0}^{\infty} \frac{1}{2^{n}}[1-\exp (-x)]^{n}, \tag{6}
\end{align*}
$$

and exploited the binomial theorem, obtaining an expression of $R_{\mathrm{ox} /}$ red as in Eq. (3) but with the series $S$ replaced by
$T=\frac{1}{2} \sum_{n=0}^{\infty} \frac{1}{2^{n}} \sum_{j=0}^{n}(-1)^{j}\binom{n}{j} w_{j}$.
Inverting the two sums in Eq. (7) and using the ordinary generating function of the binomial coefficients (for a given $j$ ) [9]
$\sum_{n=0}^{\infty}\binom{n}{j} y^{n}=\frac{y^{j}}{(1-y)^{j+1}}$,
with $y=1 / 2$, we get
$T=\frac{1}{2} \sum_{j=0}^{\infty}(-1)^{j} \sum_{n=j}^{\infty} \frac{1}{2^{n}}\binom{n}{j} w_{j}=\frac{1}{2} \sum_{j=0}^{\infty}(-1)^{j} 2 w_{j}=\sum_{j=0}^{\infty}(-1)^{j} w_{j}=S$,
which establishes the identity of the two series expressions of the integral (1). However, any application of this formula requires its truncation to a finite number of terms. Hence, the quantities of interest are the partial sums of suitable order $N$ :
$S_{N} \equiv \sum_{j=0}^{N}(-1)^{j} w_{j}$,
and
$T_{N} \equiv \frac{1}{2} \sum_{n=0}^{N} \frac{1}{2^{2}} \sum_{j=0}^{n}(-1)^{j}\binom{n}{j} w_{j}=\sum_{j=0}^{N}(-1)^{j} c_{j}(N) w_{j}$,
where the coefficients
$c_{j}(N) \equiv \sum_{n=j}^{N} \frac{1}{2^{n+1}}\binom{n}{j}$,
tend to unity for $N \rightarrow \infty$. The two partial sums $S_{N}[7]$ and $T_{N}[8]$ involve the same set of functions $w_{j}$ but with different coefficients. Such difference results from the different expansions used in the two approaches and brings about different convergence proprieties of the two solutions. As shown in Fig. 1, $T_{N}$ tends smoothly to the exact value $T$ for very small $N$ values, while $S_{N}$ shows a damped oscillation toward the same exact value, $S=T$. $T_{N}$, compared to $S_{N}$, offers a much more efficient route to the calculation of the rate constants over a wide overpotential range, all the more that most computational time is spent in evaluating the common set of functions $w_{j}$.

The continuous oscillation in the value of $S_{N}$ at each term addition is a consequence of the failure of expansion (2) at $x=0$. Because of the indeterminate character of the series for $x=0$, its


Fig. 2. Relative error $\sigma_{\text {sech }}$ made by truncating the series expansion of the hyperbolic secant in Eq. (2) to 20 (solid line) and 21 (dashed line) terms.
truncation at the $N$ th term has a relative error of $\pm 1$, with sign dependent on the parity of $N$ and magnitude independent of the value of $N$ (see Fig. 2). As $N \rightarrow \infty$, the $x$ range where the error is considerable reduces to the zero measure interval $x=0$, so that the series of integrated terms in Eq. (4) yields the exact result.

On the other hand, for $\Delta E \gg \lambda / e, S_{N}$ is very close to $S$ for each $N$. The behavior of $T_{N}$ is similar to that at smaller $\Delta E$ values, with a smooth and quick convergence to $T$ (see Fig. 3). $T_{N}-T$ finally becomes smaller than $S_{N}-S$ (right panel in Fig. 3). Notice that $N$ values less than 10 ensure a relative difference between $T_{N}$ and $T$ smaller than $0.1 \%$ over all the explored $\Delta E$ range.

Let us compare the applications of the rate constant expressions using $S_{N}$ and $T_{N}$ to the description of a typical linear sweep voltammogram. Indeed, the expressions of the interfacial rate constants in Eq. (1) have been widely used not only in the study of electrochemical redox reactions [4,5], but also in the context of redox molecular junctions [10,11]. Therefore, we will formulate our discussion on a "per molecule" basis, which, on the one hand, provides an immediate link to the literature on diffusionless electrochemical systems [12,13] and, on the other hand, can be directly exploited in the study of sequential charge transport through redox molecular junctions $[8,10,11]$. The molecule adsorbed at the electrode surface is modeled as a two-state ( $A$ and $B$ ) system. Either $A$ or $B$ can represent the oxidized or reduced adsorbate, consistently with the sign convention for $\Delta E$. On a per-molecule basis, the surface concentration of the electroactive species in a given redox state is replaced by the occupation probability $P$ of the molecular redox site. In terms of $P$ and of the rate constants $R_{A \rightarrow B}$ and $R_{B \rightarrow A}$ for the $A$-to- $B$ and $B$-to- $A$ transitions, respectively, the current at the electrode is proportional to the quantity $[12,13]$


Fig. 1. Relative errors $\sigma_{R}=\left(S_{N}-S\right) / S$ (empty squares) and $\left(T_{N}-T\right) / T$ (full squares) in the rate constant, plotted against $N$, at a fixed overpotential $\Delta E_{0}$ of (left) 0.1 V and (right) 0.6 V . The model parameters are $T=298 \mathrm{~K}, \lambda=0.7 \mathrm{eV}$.


Fig. 3. Relative errors $\sigma_{R}=\left(S_{N}-S\right) / S$ (empty squares) and $\left(T_{N}-T\right) / T$ (full squares) in the electron transfer rate constant, plotted against $N$, at $\Delta E_{0}=1.4 \mathrm{~V}$. Smaller ranges of $N$ and correspondingly of the ordinate are reported in the right panel.


Fig. 4. $J$ versus $V$, for a model system with $T=298 \mathrm{~K}, \lambda=0.15 \mathrm{eV}$, and $m=0.08$ (lower curves), 0.04 (upper curves). Left: $S=T$ as simulated by $N=30$ (full gray lines) and $T_{N}$ with $N=6$ (dash). Right: dashed lines reported from the left panel and results using $S_{N}$ with $N=6$ (full lines). Visible differences are seen between the $J-\Delta E$ responses resulting from $S_{N}$ and $T_{N}$.
$J \equiv \frac{d P}{d t}=v \frac{d P}{d V}=(1-P) R_{A \rightarrow B}(V)-P R_{B \rightarrow A}(V)$,
where $v=\Delta E / t$ is the sweep rate. The assumptions and conditions underlying the above equation as well as its suitable inclusion in a more complete mechanism that ensures charge balance through appropriate inter-phase transport are well known [14,15]. The peak position and the shape of the voltammogram resulting from Eq. (12) depend on the competition between the interfacial charge transfer rates and the scan rate, which can be quantified by the parameter $m=R_{A \rightarrow B}(0) k_{B} T / e v$ [12].

Eq. (12) has been implemented in a finite differences simulation, as described by Eq. (13) of Ref. [13], but inserting the expressions of the rate constants that result from Eq. (3) with $S$ approximated either by $S_{N}$ or by $T_{N}$. Results are shown in Fig. 4. Note that the employed small value of $\lambda$ can be easily encountered also in the context of molecular junctions [16]. The use of $T$ and $T_{N}$ with $N=6$ in the rate constants of Eq. (12) yields indistinguishable voltammograms in Fig. 4, while a visible departure from such curves results from $S_{N}$.

The value of the theoretical development in Ref. [7] is not affected by these results. Yet, Fig. 4 demonstrates that analytical conditions that may appear as mathematical 'pedantry' from the viewpoint of the description of a physical system, can lead to observable effects in the accuracy of such description. Moreover, the present analysis aims to shed light on the level of accuracy that needs to be kept truncating the series expression of the electron transfer rate constant as $S_{N}$ [7] or $T_{N}$ [8]. Ultimately, it may also
be worth reconsidering the valuable and useful reformulations and approximations of $S$ in [7] in terms of the partial sums $T_{N}$.

## Acknowledgements

This work is supported by the Israel Science Foundation, and the European Research Council under the European Union's Seventh Framework Program (FP7/2007-2013; ERC Grant agreement No. 226628). We wish to thank Antonino Messina for helpful discussions.

## References

[1] R.A. Marcus, Annu. Rev. Phys. Chem. 15 (1964) 155-196.
[2] R.A. Marcus, J. Chem. Phys. 43 (1965) 679-701.
[3] N.S. Hush, Electrochim. Acta 13 (1968) 1005-1023.
[4] W. Schmickler, Electrochim. Acta 20 (1975) 137-141 (and references therein).
[5] C.E.D. Chidsey, Science 251 (1991) 919-922 (and references therein).
[6] C. Léger, P. Bertrand, Chem. Rev. 108 (2008) 2379-2438.
[7] K.B. Oldham, J.C. Myland, J. Electroanal. Chem. 655 (2011) 65-72.
[8] A. Migliore, A. Nitzan, ACS Nano 5 (2011) 6669-6685.
[9] P. Flajolet, R. Sedgewick, Analytic Combinatorics, Cambridge University Press, 2009.
[10] A.M. Kuznetsov, I.G. Medvedev, Phys. Rev. B 78 (2008) 153403.
[11] A.M. Kuznetsov, I.G. Medvedev, J. Ulstrup, J. Chem. Phys. 131 (2009) 164703.
[12] E. Laviron, J. Electroanal. Chem. 101 (1979) 19-28.
[13] M.J. Honeychurch, Langmuir 15 (1999) 5158-5163 (and references therein).
[14] G.G. Láng, G. Horányi, Electroanalysis 11 (1999) 905-906.
[15] M.J. Honeychurch, G.A. Rechnitz, Electroanalysis 11 (1999) 907-908.
[16] S.W. Robey, J.W. Ciszek, J.M. Tour, J. Phys. Chem. C 111 (2007) 17206-17212.


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